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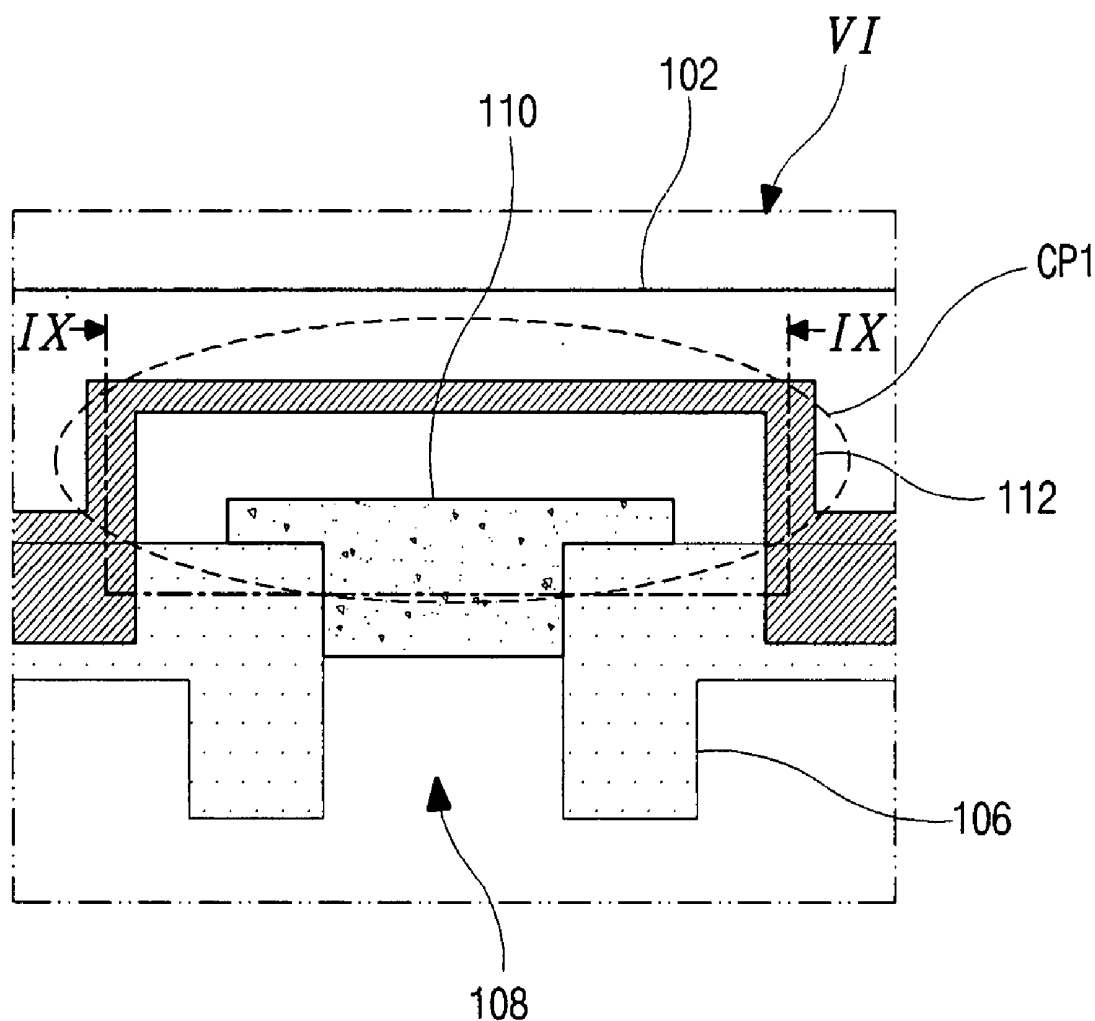
(51) Int. Cl.
G02F 1/1339 (2006.01)

(52) **U.S. Cl.** 349/153; 349/190

(57) **ABSTRACT**

A liquid crystal display (LCD) device includes: a first substrate opposite a second substrate and coupled to the second substrate by a first seal pattern; a liquid crystal layer interposed between the first and second substrates within the first seal pattern; a second seal pattern sealing an injection hole in the first seal pattern; and a common line disposed at a first surface of the first substrate and having a predetermined pattern that exposes the second seal pattern to a second surface of the first substrate.

Dec. 4, 2006 (KR) 2006-0121605



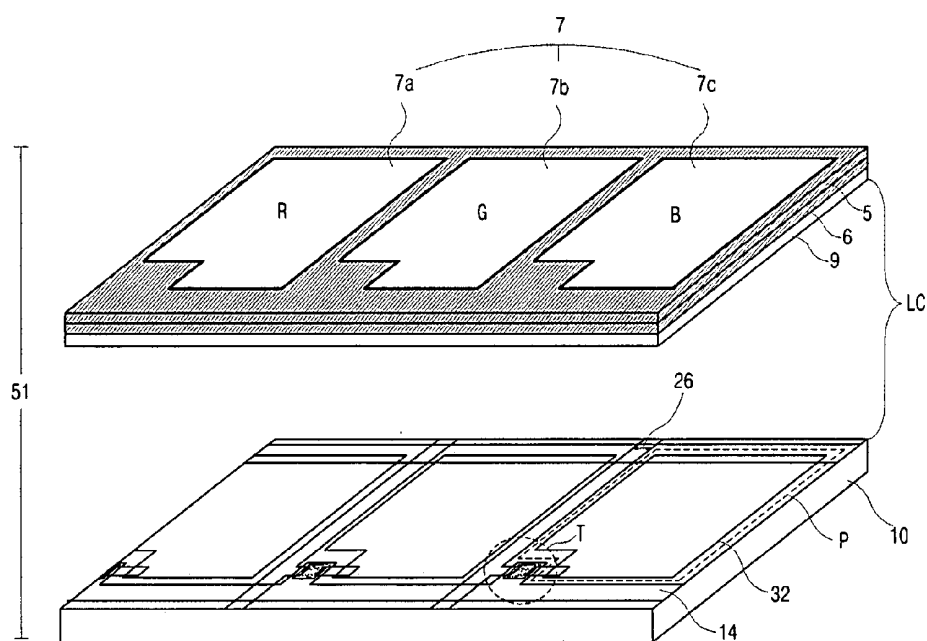


FIG. 1

(RELATED ART)

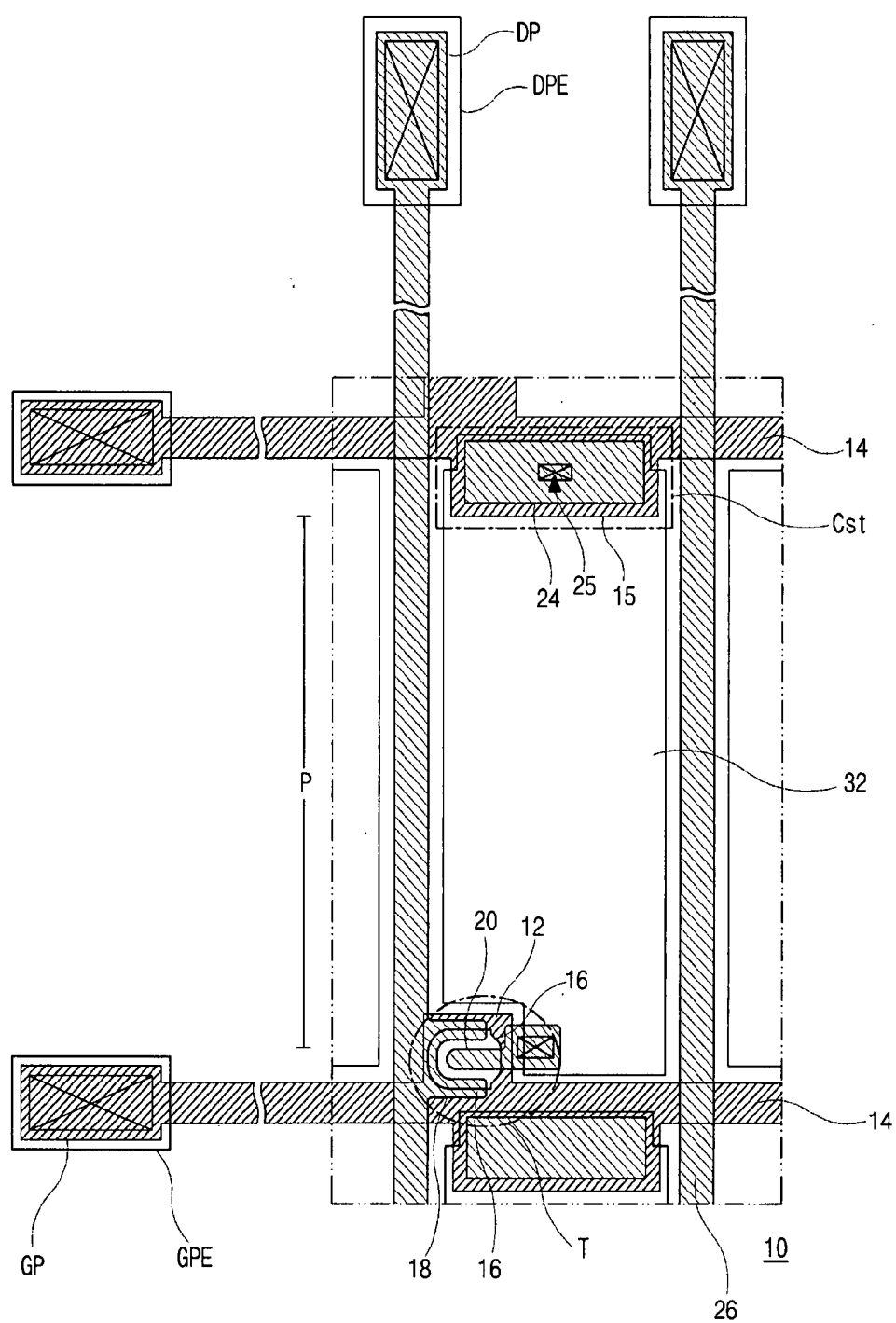


FIG. 2

(RELATED ART)

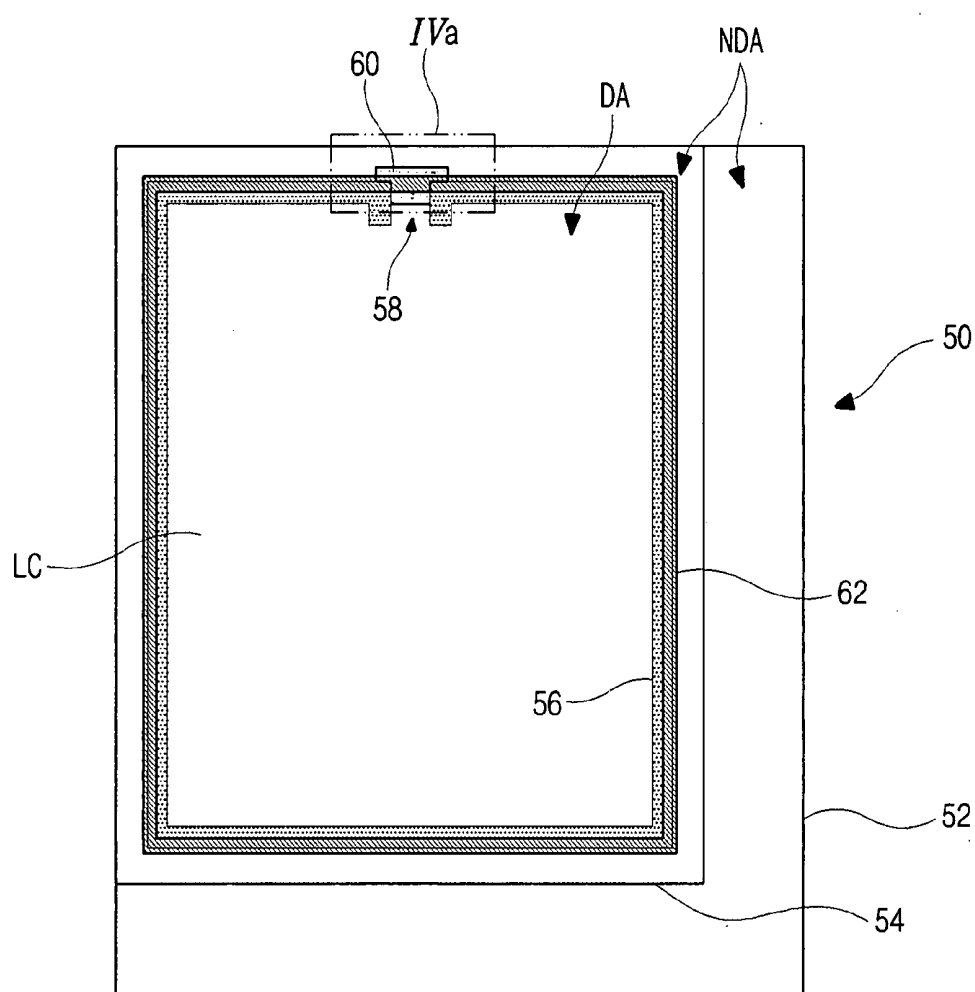


FIG. 3

(RELATED ART)

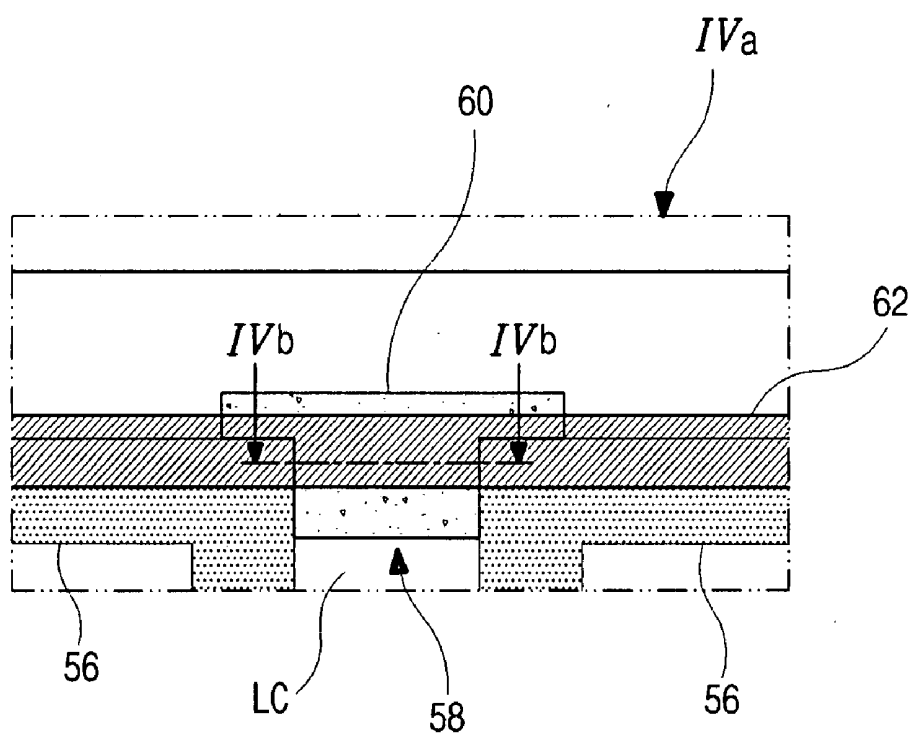


FIG. 4A

(RELATED ART)

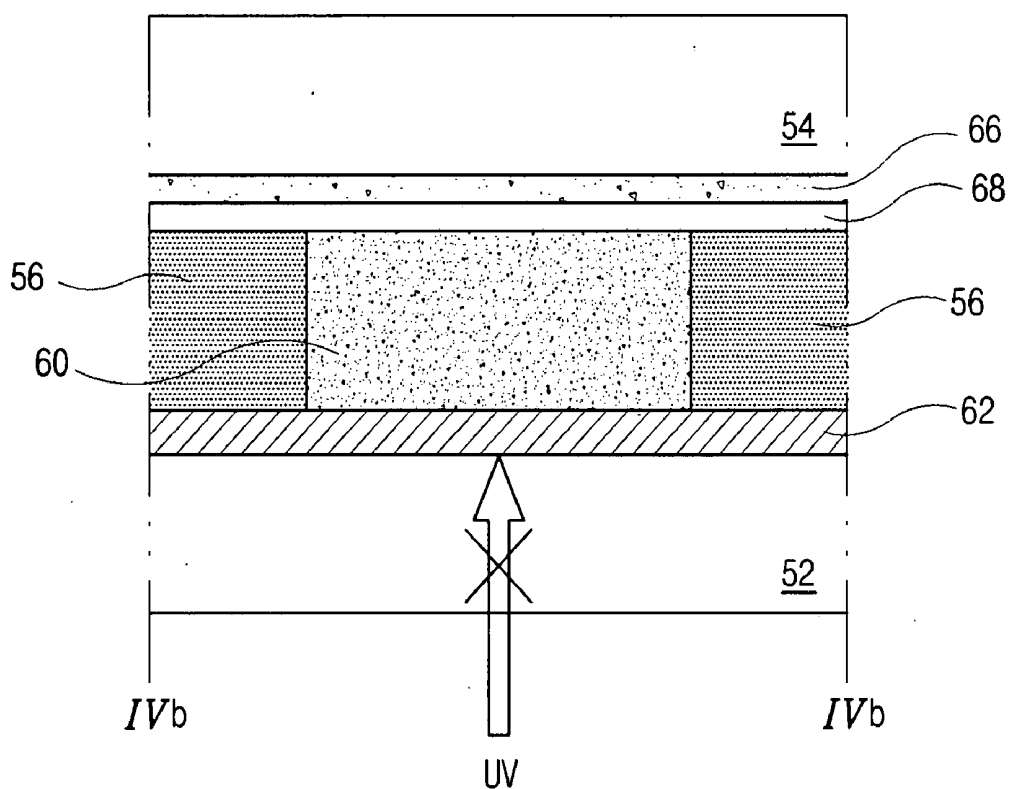


FIG. 4B

(RELATED ART)

FIG. 5

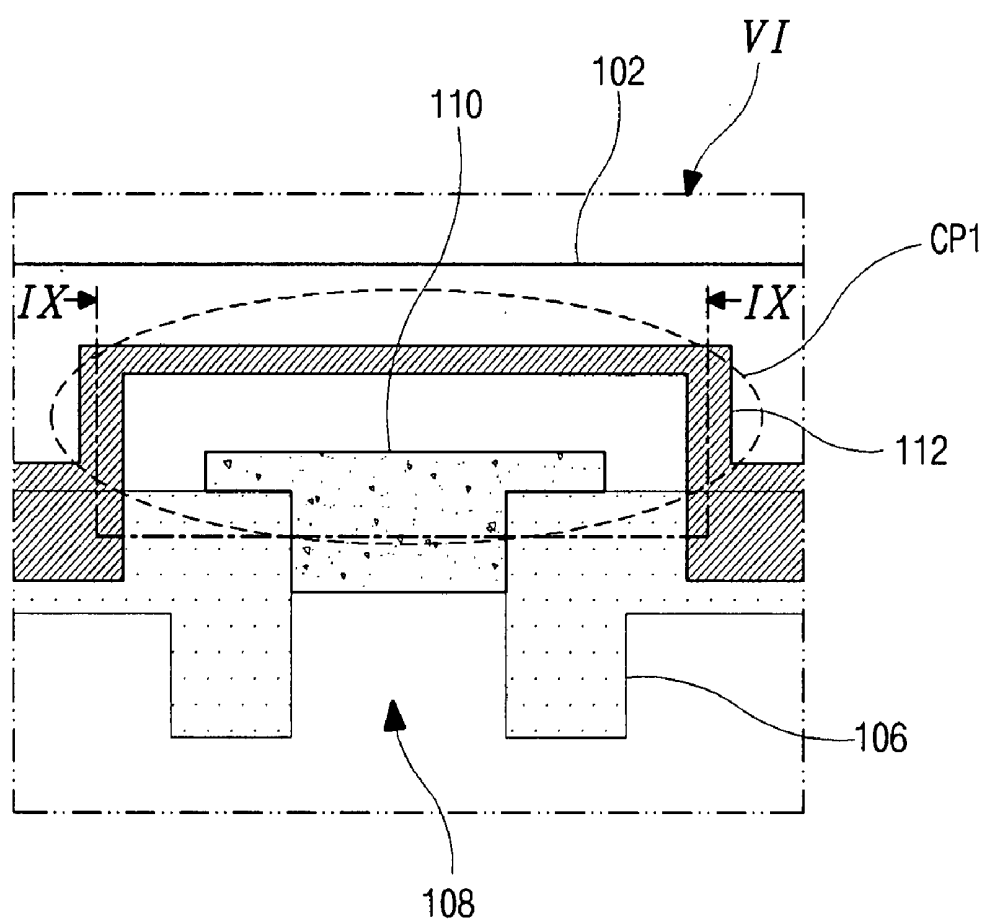


FIG. 6

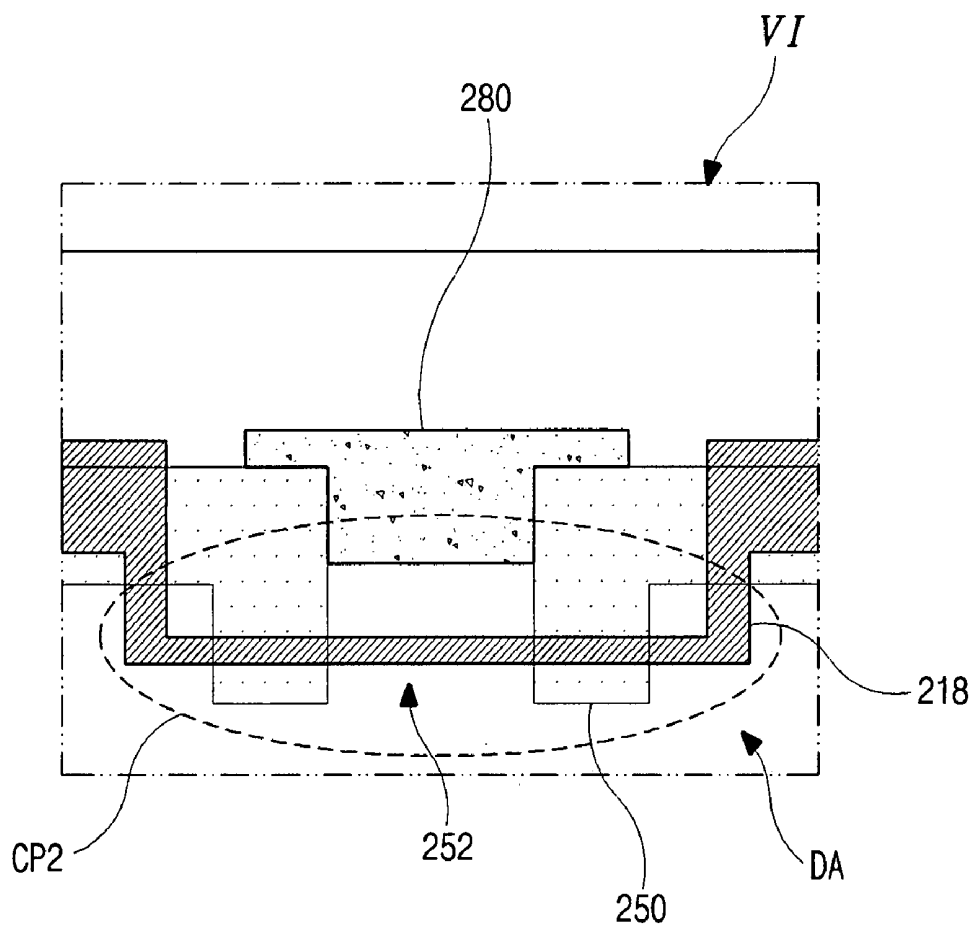


FIG. 7

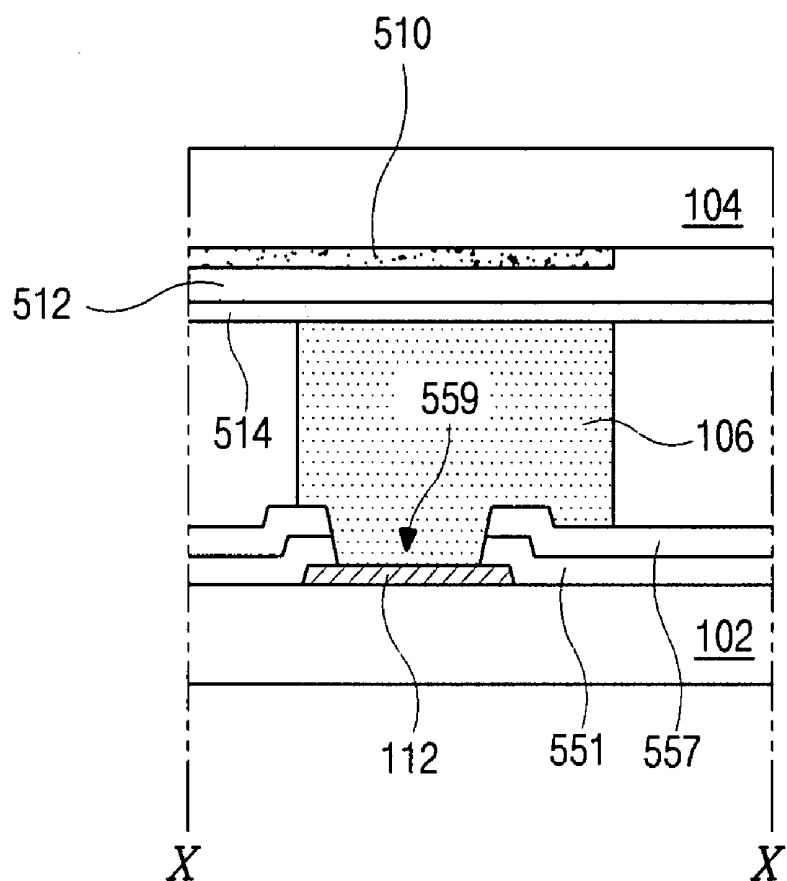


FIG. 10A

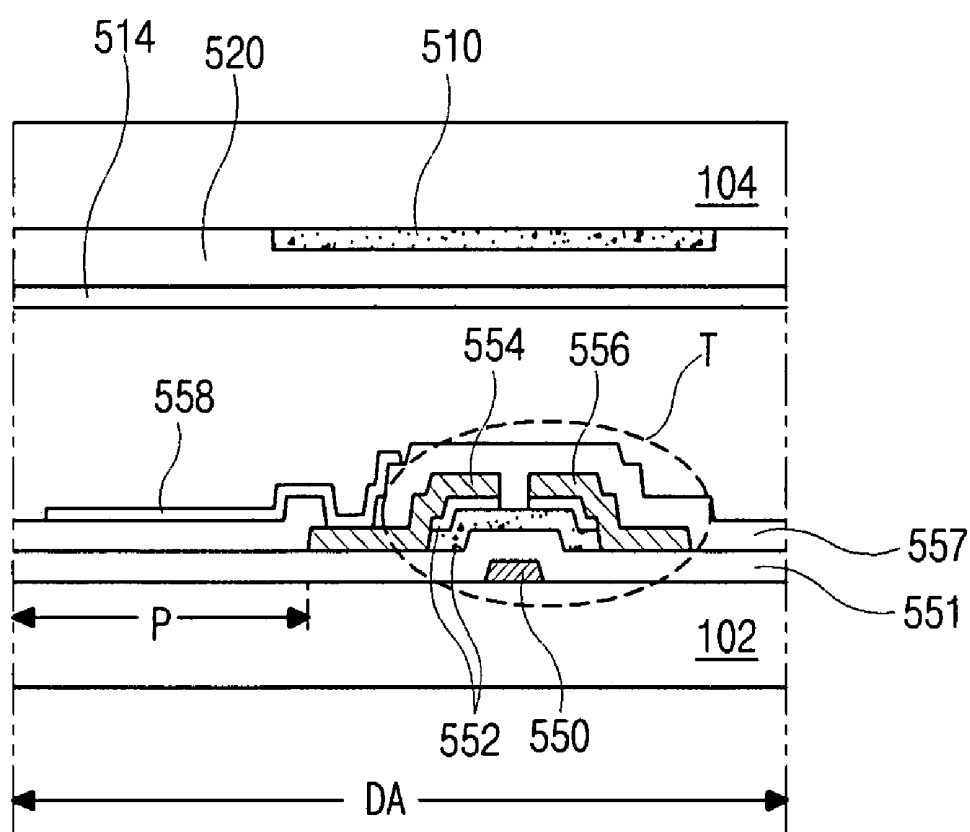


FIG. 10B

LIQUID CRYSTAL DISPLAY DEVICE

[0001] This application claims the benefit of Korean Patent Application No. 10-2006-0121605, filed on Dec. 4, 2006 in Korea, which is hereby incorporated by reference for all purposes as if fully set forth herein.

BACKGROUND

[0002] 1. Technical Field

[0003] The present invention relates to a liquid crystal display device, and more particularly, to a liquid crystal display (LCD) device and a method of fabricating the same.

[0004] 2. Discussion of the Related Art

[0005] Until recently, display devices have typically used cathode-ray tubes (CRTs). Presently, many efforts and studies are being made to develop various types of flat panel displays, such as liquid crystal display (LCD) devices, plasma display panels (PDPs), field emission displays, and electro-luminescence displays (ELDs), as a substitute for CRTs. Of these flat panel displays, LCD devices have many advantages, such as high resolution, light weight, thin profile, compact size, and low voltage power supply requirements.

[0006] In general, an LCD device includes two substrates that are spaced apart and face each other with a liquid crystal material interposed between the two substrates. The two substrates include electrodes that face each other such that a voltage applied between the electrodes induces an electric field across the liquid crystal material. Alignment of the liquid crystal molecules in the liquid crystal material changes in accordance with the intensity of the induced electric field into the direction of the induced electric field, thereby changing the light transmittance of the LCD device. Thus, the LCD device displays images by varying the intensity of the induced electric field.

[0007] FIG. 1 is a schematic perspective view illustrating an LCD device according to the related art.

[0008] In FIG. 1, the LCD device 51 includes an upper substrate 5, a lower substrate 10 facing and spaced apart from the upper substrate 5, and a liquid crystal layer "LC" between the upper and lower substrates 5 and 10.

[0009] A gate line 14 and a data line 26 cross each other to define a pixel region "P" on an inner surface of the lower substrate 10, a thin film transistor "T" is formed at crossing the gate line 14 and the data line 26, and a pixel electrode 32 is connected to the thin film transistor "T" in the pixel region "P."

[0010] Further, a black matrix 6 is formed on an inner surface of the upper substrate 5, a color filter layer 7 is formed on the black matrix 6, and a common electrode 9 is formed on the color filter layer 7. Here, the color filter layer 7 includes red, green and blue sub-color filters 7a, 7b and 7c. Each of the red, green and blue sub-color filters 7a, 7b and 7c is disposed in the pixel region "P," and the black matrix 6 is disposed in a non-pixel region (not shown) in a periphery of the pixel region "P."

[0011] The first and second substrates 5 and 10 are attached with a seal pattern (not shown). The LCD device 51 operates with signals from an external printed circuit board (not shown). The gate line 14 is supplied with a gate signal, the data line 26 is supplied with a data signal, and the common electrode 9 is supplied with a common signal.

[0012] The gate signal switches the thin film transistor "T" and the data signal is applied to the pixel electrode 32. By applying the pixel and common electrodes 32 and 9 to the corresponding signals, an electric field is induced. Liquid crystal molecules of the liquid crystal layer "LC" are

arranged by the induced electric field, and the light transmittance of the LCD device 51 is changed, thus images are displayed.

[0013] A gate pad and a data pad (not shown) are formed at one ends of the gate line 14 and the data line 26 to be supplied with the gate signal and the data signal, respectively.

[0014] FIG. 2 is a schematic plan view illustrating an array substrate for an LCD device according to the related art.

[0015] In FIG. 2, the gate line 14 and the data line 26 crosses each other to define the pixel region "P" on the upper substrate 10. A gate pad "GP" is at one end of the gate line 14, and a data pad "DP" is at one end of the data line 26. A gate pad electrode "GPE" contacts and is on the gate pad "GP," and a data pad electrode "DPE" contacts and is on the data pad "DP". A thin film transistor "T" is located at a crossing of the gate and data lines 14 and 26. The thin film transistor "T" includes a gate electrode 12, a semiconductor layer 16 and source and drain electrodes 18 and 20. A pixel electrode 32 is disposed in the pixel region "P" and connected to the drain electrode 20.

[0016] A first capacitor electrode 15 extends from the gate line 14, and a second capacitor electrode 24 overlaps with the first capacitor electrode 15 and is connected to the pixel electrode 32 via a contact hole 25. The first and second capacitor electrodes 15 and 24 and an insulating layer (not shown) therebetween constitute a storage capacitor "Cst."

[0017] The gate and data pads "GP and DP" are disposed in a non-display region (not shown). Other signals lines are also formed in the non-display region, for example, a common line (not shown) is formed in the non-display region. When a small-sized LCD device is fabricated, the first and second substrates 5 and 10 (of FIG. 1) are attached with a conductive seal pattern (not shown). The common line (not shown) contacts the conductive seal pattern to supply a common signal to the common electrode 9 (FIG. 1).

[0018] FIG. 3 is a schematic plan view illustrating an LCD device according to the related art.

[0019] In FIG. 3, the LCD device 50 includes first and second substrates 52 and 54 attached with a conductive seal pattern 56. The LCD device 50 has a display region "DA" and a non-display region "NDA" in a periphery of the display region "DA."

[0020] When the first substrate 52 is an array substrate and the second substrate 54 is a color filter substrate, the first substrate 52 protrudes beyond the second substrate 54.

[0021] The conductive seal pattern 56 attaches the first and second substrates 52 and 54 and maintains a cell gap between the first and second substrates 52 and 54. Further, the conductive seal pattern 56 has an injection hole 58 for injecting a liquid crystal layer "LC" between the first and second substrates 52 and 54, and an adhesive pattern 60 seals the injection hole 58 after injecting the liquid crystal layer "LC." Further, a common line 62 is formed at a boundary between the display region "DA" and the non-display region "NDA" to contact the conductive seal pattern 56. Therefore, a portion of the common line 62 overlaps with the adhesive pattern 60 at the injection hole 58 in a plan view. Here, the common line 62 is formed with the same material and through the same process as the gate line 14 (of FIG. 2).

[0022] During manufacturing, a plurality of liquid crystal panels are arranged with the injection holes 58 facing upward, and one side of the liquid crystal panels are rubbed with sealing material using a roller which has sealing material thereon. The sealing material permeates inside of the injection hole 58 by a capillary phenomenon. The sealing material of the adhesive pattern 60 is hardened by irradiating UV (ultra violet) light and thus able to seal the injection hole 58. Gen-

erally, the UV light is irradiated from the first substrate **52** to the second substrate **54**, so a portion of the adhesive pattern **60** overlapping with the common line **62** is uncured.

[0023] FIGS. 4A and 4B are schematic views illustrating a region of an injection hole for an LCD device according to the related art. FIG. 4A is an expanded view of an area "IVa" of FIG. 3, and FIG. 4B is a cross-sectional view taken along a line "IVb-IVb" of FIG. 4A.

[0024] In FIGS. 4A and 4B, the injection hole **58** of the conductive seal pattern **56** is sealed by the adhesive pattern **60**. That is, the liquid crystal layer "LC" can be shielded from outside by the adhesive pattern **60**. As explained above, the adhesive pattern **60** can properly act as a sealing means when the adhesive pattern **60** is completely hardened. However, the adhesive pattern **60** cannot be completely hardened because the adhesive pattern **60** overlaps with the common line **62** which is disposed at an irradiating direction of the UV light. Therefore, the adhesive pattern **60** is partially hardened due to the common line **62**, so the adhesive pattern **60** may mix with the liquid crystal layer "LC." Even if the UV light is irradiated toward the second substrate **54**, a black matrix **66** on the second substrate **54** shields the adhesive pattern **60**.

[0025] Therefore, the adhesive pattern **60** is not completely hardened after hardening process, so the uncured portion of the adhesive pattern **60** may be mixed with a portion of the liquid crystal layer "LC" contacting the adhesive pattern **60**. Accordingly, the adhesive pattern **60** acts as impurities in the liquid crystal layer "LC," so an image defect occurs such as light leakage or screen stain.

[0026] Specifically, as shown in FIG. 4B, the common line **62** is formed on the first substrate **52**, the conductive seal pattern **56** including the injection hole **58** and the adhesive pattern **60** in the injection hole **58** are formed on the common line **62**.

[0027] A black matrix **66** is formed on the second substrate **54** and a common electrode **68** is formed on the black matrix **66**. That is, the conductive seal pattern **56** and the adhesive pattern **60** are disposed between the common line **62** and the common electrode **68**. As shown in FIG. 4B, the UV light does not reach the adhesive pattern **60** because the common line **62** interrupts irradiation of the UV light onto the adhesive pattern **60**.

SUMMARY

[0028] In one embodiment, a liquid crystal display (LCD) device includes: a first substrate opposite a second substrate and coupled to the second substrate by a first seal pattern; a liquid crystal layer interposed between the first and second substrates within the first seal pattern; a second seal pattern sealing an injection hole in the first seal pattern; and a common line disposed at a first surface of the first substrate and having a predetermined pattern that exposes the second seal pattern to a second surface of the first substrate.

[0029] In another embodiment, a method of fabricating a liquid crystal display device includes: forming a common line with a predetermined pattern on a first surface of a first substrate; coupling the first substrate with a second substrate using a first seal pattern; injecting a liquid crystal layer between the first and second substrates through an injection hole in the first seal pattern; sealing the injection hole with a second seal pattern; and hardening the second seal pattern; wherein the predetermined pattern exposes the second seal pattern to reduce a blocking of the second seal pattern by the common line.

[0030] It is to be understood that both the foregoing general description and the following detailed description are exem-

plary and explanatory and are intended to provide further explanation of the invention as claimed.

BRIEF DESCRIPTION OF THE DRAWING

[0031] The accompanying drawings, which are included to provide a further understanding of the invention and are incorporated in and constitute a part of this specification, illustrate embodiments of the invention and together with the description serve to explain the principles of the invention. In the drawings:

[0032] FIG. 1 is a schematic perspective view illustrating an LCD device according to the related art;

[0033] FIG. 2 is a schematic plan view illustrating an array substrate for an LCD device according to the related art;

[0034] FIG. 3 is a schematic plan view illustrating an LCD device according to the related art;

[0035] FIGS. 4A and 4B are schematic views illustrating a region of an injection hole for an LCD device according to the related art;

[0036] FIG. 5 is a schematic plan view illustrating an LCD device according to an embodiment of the present invention;

[0037] FIG. 6 is an expanded view of an area "VI" of FIG. 5 according to an embodiment of the present invention;

[0038] FIGS. 7 and 8 are schematic plan view illustrating a region of an injection hole of an LCD device according to embodiments of the present invention;

[0039] FIG. 9 is a schematic cross-sectional view taken along a line "IX-IX" of FIG. 6 according to an embodiment of the present invention; and

[0040] FIGS. 10A and 10B are cross-sectional views illustrating an LCD device according to an embodiment of the present invention.

DETAILED DESCRIPTION

[0041] Reference will now be made in detail to the illustrated embodiment of the present invention, which is illustrated in the accompanying drawings. Wherever possible, similar reference numbers will be used throughout the drawings to refer to the same or like parts.

[0042] FIG. 5 is a schematic plan view illustrating an LCD device according to an embodiment of the present invention. FIG. 6 is an expanded view of an area "VI" of FIG. 5 according to an embodiment of the present invention.

[0043] In FIGS. 5 and 6, the LCD device **100** includes first and second substrates **102** and **104** attached with a first seal pattern **106**, and a liquid crystal layer **120** is interposed within the first seal pattern **106** between the first and second substrates **102** and **104**. Specifically, the first seal pattern **106** includes an injection hole **108**, and the injection hole **108** is sealed using a second seal pattern **110** after injecting the liquid crystal layer **120**. In particular, the first seal pattern **106** includes a conductive sealant that has a glass fiber and a conductive ball which includes gold (Au).

[0044] The LCD device **100** has a display region "DA" and a non-display region "NDA" in a periphery of the display region "DA."

[0045] For example, when the first substrate **102** is an array substrate and the second substrate **104** is a color filter substrate, the first substrate **102** protrudes beyond from the second substrate **104**. In the protruded portion of the first substrate **102**, although not shown, a driving circuit is connected to the gate and data pads "GP and DP" (FIG. 2) and a connector (not shown) is connected to a PCB (not shown). The connector is connected to the driving circuit to transfer signals from the PCB. However, although the protruded portion of the first substrate **102** is defined at two sides of the first

substrate **102** as shown in FIG. 5, the protruded portion of the first substrate **102** may be defined at one side of the first substrate **102**. In other words, the driving circuits may be formed at one side of the first substrate **102** in the non-display region "NDA."

[0046] The liquid crystal layer **120** can maintain its shape by the first seal pattern **106**. Further, a common line **112** surrounds a boundary between the display region "DA" and the non-display region "NDA" to contact the first seal pattern **106**.

[0047] In particular, the common line **112** has a convex pattern "CPI" at the injection hole **108** to expose the second seal pattern **110** toward the first substrate **102**. Accordingly, the second seal pattern **110** can be completely hardened through the curing process because the UV light is directly passed onto the second seal pattern **110** without any metal pattern between the first substrate **102** and the second seal pattern **110**. That is, because the second seal pattern does not have an uncured portion, an image defect due to the uncured portion of the second seal pattern **110** does not occur.

[0048] In accordance with the illustrated embodiment, the common line **112** has a closed shape without an opening. If the common line **112** has an opening, static electricity between facing portions of the common line **112** at the opening may be generated. Therefore, the common line **112** that is electrically connected to a common electrode (not shown) using the first seal pattern of the conductive sealant should have a closed shape to prevent the image defect due to the static electricity.

[0049] FIGS. 7 and 8 are schematic plan views illustrating a region of an injection hole of an LCD device according to embodiments of the present invention.

[0050] In FIG. 7, a common line **218** includes a concave pattern "CP2" that is bent toward the display region "DA" to expose a second seal pattern **280**.

[0051] Alternatively, as shown in FIG. 8, a common line **318** has a slit portion "SP" including a plurality of slits **320** at a portion of an injection hole **352** to partially expose a second seal pattern **380**. Specifically, the second seal pattern **380** can be completely hardened by diffraction exposing due to the plurality of slits **320** without an uncured portion.

[0052] FIG. 9 is a schematic cross-sectional view taken along a line "IX-IX" of FIG. 6 according to an embodiment of the present invention.

[0053] In FIG. 9, the common line **112** including the convex pattern "CPI" is formed on an inner surface of the first substrate **102**, the first seal pattern **106** including the injection hole **108** is formed on the common line **112** and the first substrate **102**, and the second seal pattern **110** is formed at the injection hole **108**. A black matrix **410** is formed on an inner surface of the second substrate **104**, and a common electrode **412** is formed on the black matrix **410**. Although not shown, a color filter layer (not shown) is formed between the black matrix **410** and the common electrode **412** in the display region "DA" (FIG. 5).

[0054] As shown in FIG. 9, the common line **112** does not shield the second seal pattern **110**, so UV light can be reached to the second seal pattern **110** without any metal line between the first substrate **102** and the second seal pattern **104**. Accordingly, the second seal pattern **110** can be completely hardened.

[0055] FIGS. 10A and 10B are cross-sectional views illustrating an LCD device according to an embodiment of the present invention. FIG. 10A is a view taken along a line "X-X" of FIG. 5, and FIG. 10B is a view illustrating a display region of the LCD device.

[0056] In FIG. 10A, the common line **112** is formed on the inner surface of the first substrate **102**, and the first seal pattern **106** contacts the common line **112**. Further, a black matrix **510** is formed on the inner surface of the second substrate **104**, a dummy color filter pattern **512** is formed on the black matrix **510**, and the common electrode **514** is formed on the dummy color filter pattern **512**. Although not shown, the first seal pattern **106** includes a glass fiber and a conductive ball which includes gold (Au). That is, the first seal pattern **106** can electrically connect the common line **112** and the common electrode **514** using the conductive ball therein.

[0057] In FIG. 10B, a thin film transistor "T," which includes a gate electrode **550**, a semiconductor layer **552**, source and drain electrodes **554** and **556**, is formed on an inner surface of the first substrate **102**, and a pixel electrode **558** is connected to the thin film transistor "T" in the pixel region "P." Further, the black matrix **510** is formed on the inner surface of the second substrate **104**, a color filter layer **520** is formed on the black matrix **510** in the pixel region "P," and the common electrode **514** is formed on the color filter layer **520**. Here, the dummy color filter pattern **512** (of FIG. 10A) does not act as the color filter layer **520**, but the dummy color filter pattern **512** is formed with the same material as the color filter layer **520**. However, the color filter layer **520** may be formed on the first substrate **102** and not on the second substrate **104**. Further, the dummy color filter pattern **512** may be omitted as shown in FIG. 9.

[0058] As illustrated in FIG. 10B, a gate insulating layer **551** is formed between the gate electrode **550** and the semiconductor layer **552**, and a passivation layer **557** is formed between the thin film transistor "T" and the pixel electrode **558**. The gate insulating layer **551** and the passivation layer **557** are formed between the common line **112** and the first seal pattern **106** and have a contact hole **559** that exposes a portion of the common line **112** to connect the common line **112** and the first seal pattern **106** as shown in FIG. 10A.

[0059] That is, the common line **112** and the gate electrode **550** are formed with the same material on the same layer as each other. However, the common line **112** may be formed with a different material on a different layer from the gate electrode **550**.

[0060] Although not shown, a gate line is connected to the gate electrode **550** along a first direction, and a gate pad is formed at an end portion of the gate line. Further, a data line is connected to the source electrode along a second direction crossing the first direction to define the pixel region "P;" and a data pad is formed at an end portion of the data line. For example, a portion of the gate line crossing the common line **112** is formed with the same material as the data line to prevent shorting between the common line **112** and the gate line. For example, the gate line and the gate pad are connected to a gate link line of the same material as the data line at an overlapped portion with the common line **112**.

[0061] Although not shown, a method for fabricating the LCD device may include forming the common line on the first substrate, forming the first seal pattern including the injection hole on the common line, forming a common electrode on a second substrate, attaching the first and second substrates with the first seal pattern, injecting a liquid crystal layer into the injection hole, sealing the injection hole using a second seal pattern, and curing the second seal pattern toward the first substrate, wherein the common line exposes the second seal pattern toward the first substrate.

[0062] According to the LCD device, since the common line does not overlap with the second seal pattern, the second seal pattern is completely hardened. Therefore, image defects

such as light leakage or screen stain due to the uncured second seal pattern are not generated. Therefore, a high image quality can be obtained.

[0063] While the invention has been particularly shown and described with reference to an illustrated embodiment thereof, it will be understood by those skilled in the art that the foregoing and other changes in form and details may be made therein without departing from the spirit and scope of the invention.

What is claimed is:

1. A liquid crystal display (LCD) device, comprising:
 - a first substrate opposite a second substrate and coupled to the second substrate by a first seal pattern;
 - a liquid crystal layer interposed between the first and second substrates within the first seal pattern;
 - a second seal pattern sealing an injection hole in the first seal pattern; and
 - a common line disposed at a first surface of the first substrate and having a predetermined pattern that exposes the second seal pattern to a second surface of the first substrate.
2. The LCD device of claim 1 wherein the first surface is an inner surface of the first substrate and the second surface is an outer surface of the first substrate.
3. The LCD device of claim 2 wherein the outer surface of the first substrate is adjacent a light source, further wherein the second seal pattern is exposed to the light source.
4. The LCD device of claim 1 further comprising:
 - a gate line and a data line crossing each other on the first surface of the first substrate;
 - a thin film transistor disposed at the crossing of the gate line and the data line; and
 - a pixel electrode connected with the thin film transistor.
5. The LCD device of claim 4, wherein the common line is formed at the same layer and with the same material as the gate line.
6. The LCD device of claim 1 further comprising a common electrode on a first surface of the second substrate, the common electrode connected with the common line by the first seal pattern.
7. The LCD device of claim 1, wherein the predetermined pattern of the common line is a convex pattern, wherein the common line is spaced apart from the second seal pattern away from the liquid crystal layer.
8. The LCD device of claim 1, wherein the predetermined pattern of the common line is a concave pattern, wherein the common line is spaced apart from the second seal pattern toward the liquid crystal layer.
9. The LCD device of claim 1, wherein the predetermined pattern of the common line includes a plurality of slits in the common line.
10. The LCD device of claim 1, wherein the first seal pattern comprises a plurality of conductive balls.
11. The LCD device of claim 1, wherein the common line has a closed shape.
12. The LCD device of claim 1, wherein the first seal pattern is connected to the common line via a contact hole in an insulating layer, the contact hole exposing a portion of the common line.

13. The LCD device of claim 1 further comprising a black matrix layer, wherein the second seal pattern resides between the common line and the black matrix layer.

14. The LCD device of claim 1, wherein the first substrate and the predetermined pattern of the common line are arranged to provide an optical pathway through the first substrate.

15. A method of fabricating a liquid crystal display device, comprising:

- forming a common line with a predetermined pattern on a first surface of a first substrate;
 - coupling the first substrate with a second substrate using a first seal pattern;
 - injecting a liquid crystal layer between the first and second substrates through an injection hole in the first seal pattern;
 - sealing the injection hole with a second seal pattern; and
 - hardening the second seal pattern;
- wherein the predetermined pattern exposes the second seal pattern to reduce a blocking of the second seal pattern by the common line.

16. The method of claim 15 wherein the hardening of the second seal pattern comprises curing the second pattern with an irradiation source.

17. The method of claim 16 wherein the predetermined pattern exposes the second seal pattern to the irradiation source.

18. The method of claim 15 wherein the first seal pattern is disposed at edge of the first substrate.

19. The method of claim 15 wherein the second seal pattern is disposed at the injection hole;

20. The method of claim 15 wherein the common line surrounds an edge of the first substrate.

21. The method of claim 15 further comprising:

- forming a gate line and a data line crossing each other on the first substrate;
- forming a thin film transistor at the crossing of the gate line and the data line; and
- forming a pixel electrode connected to the thin film transistor.

22. The method of claim 15 further comprising forming a common electrode on a first surface of the second substrate, the common electrode coupled with the common line by the first seal pattern.

23. The method of claim 15, wherein the predetermined pattern of the common line is formed in a convex pattern, wherein the common line is spaced apart from the second seal pattern away from the liquid crystal layer.

24. The method of claim 15, wherein the predetermined pattern of the common line is formed in a concave pattern, wherein the common line is spaced apart from the second seal pattern toward the liquid crystal layer.

25. The method of claim 15, wherein the predetermined pattern of the common line is formed to include a plurality of slits in the common line.

* * * * *

专利名称(译)	液晶显示装置		
公开(公告)号	US20080129945A1	公开(公告)日	2008-06-05
申请号	US11/810859	申请日	2007-06-07
[标]申请(专利权)人(译)	乐金显示有限公司		
申请(专利权)人(译)	LG 飞利浦LCD CO. , LTD.		
当前申请(专利权)人(译)	LG DISPLAY CO. LTD.		
[标]发明人	KIM JEONG HUN		
发明人	KIM, JEONG-HUN		
IPC分类号	G02F1/1339		
CPC分类号	G02F1/1341 G02F1/1339		
优先权	1020060121605 2006-12-04 KR		
其他公开文献	US7714951		
外部链接	Espacenet USPTO		

摘要(译)

一种液晶显示 (LCD) 装置，包括：第一基板，与第二基板相对，并通过第一密封图案与第二基板连接;在第一密封图案内插入第一和第二基板之间的液晶层;密封第一密封图案中的注入孔的第二密封图案;公共线设置在第一基板的第一表面上并具有预定图案，该图案将第二密封图案暴露于第一基板的第二表面。

